

大面積Micro Pixel Chamberの開発 4

京都大学

永吉 勉

谷森 達、窪 秀利、身内 賢太朗、
竹田 敦、折戸 玲子、植野 優、
高田 淳史、岡田 葉子

Oleg Bouianov,

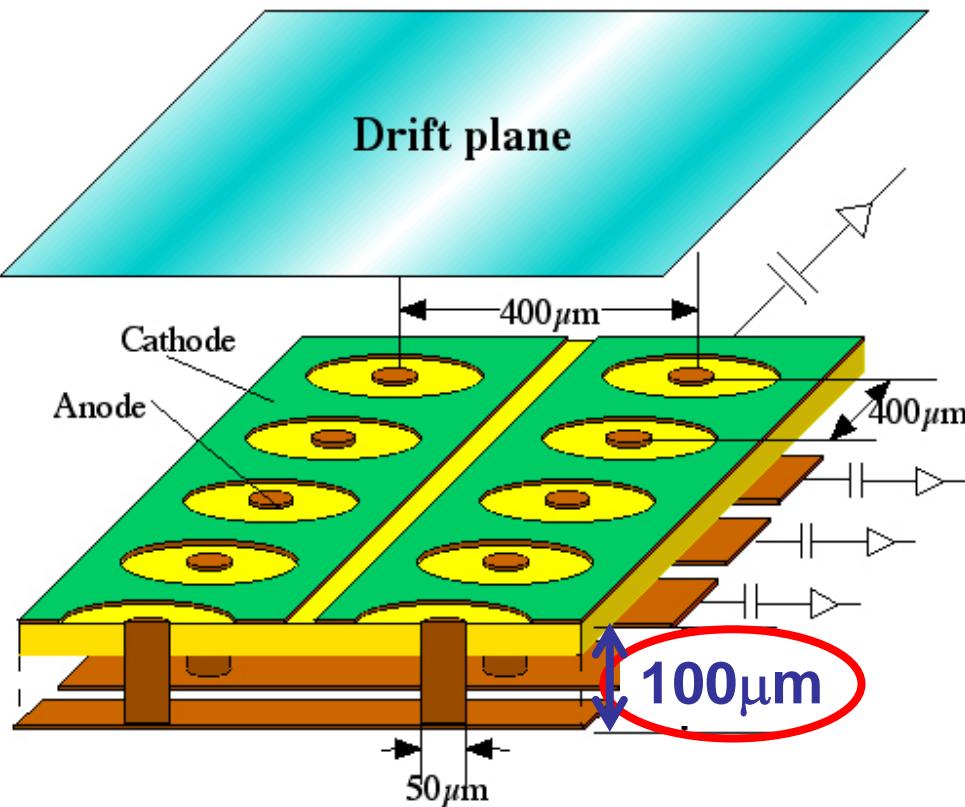
Marina Bouianov

MIT
Helsinki Univ.
of Technology

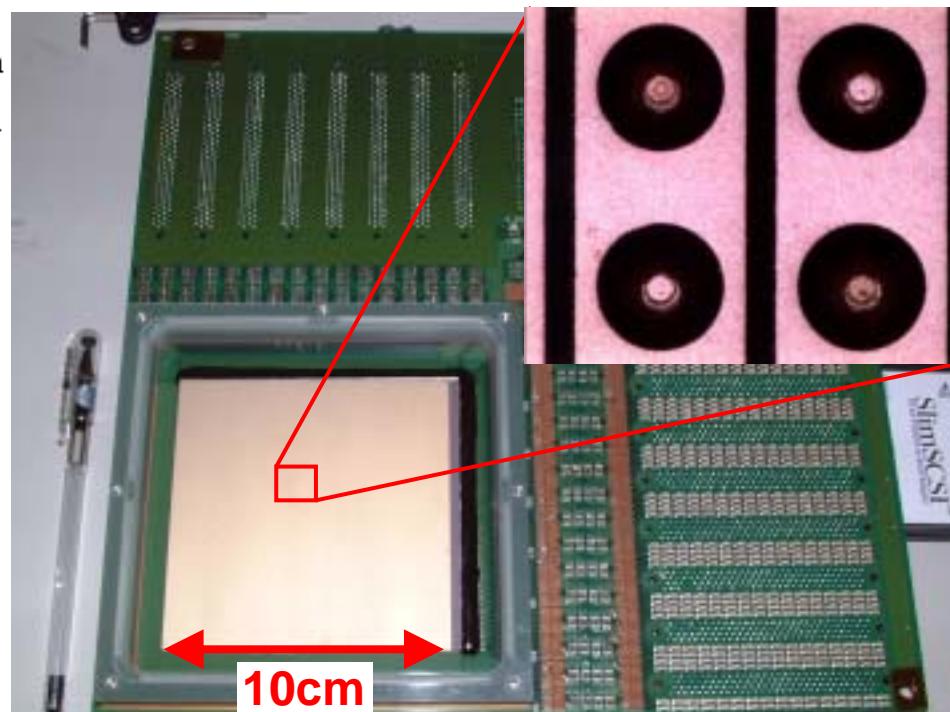
Contents

- Micro Pixel Chamber
- Simulation study
 - ✓ Electron collection (\rightarrow net gas gain)
 - ✓ Electric field (\rightarrow discharges)
- Large area detector
- Summary

Micro Pixel Chamber (μ -PIC)



- PCB technology
- Pixel electrode
- 2D readout

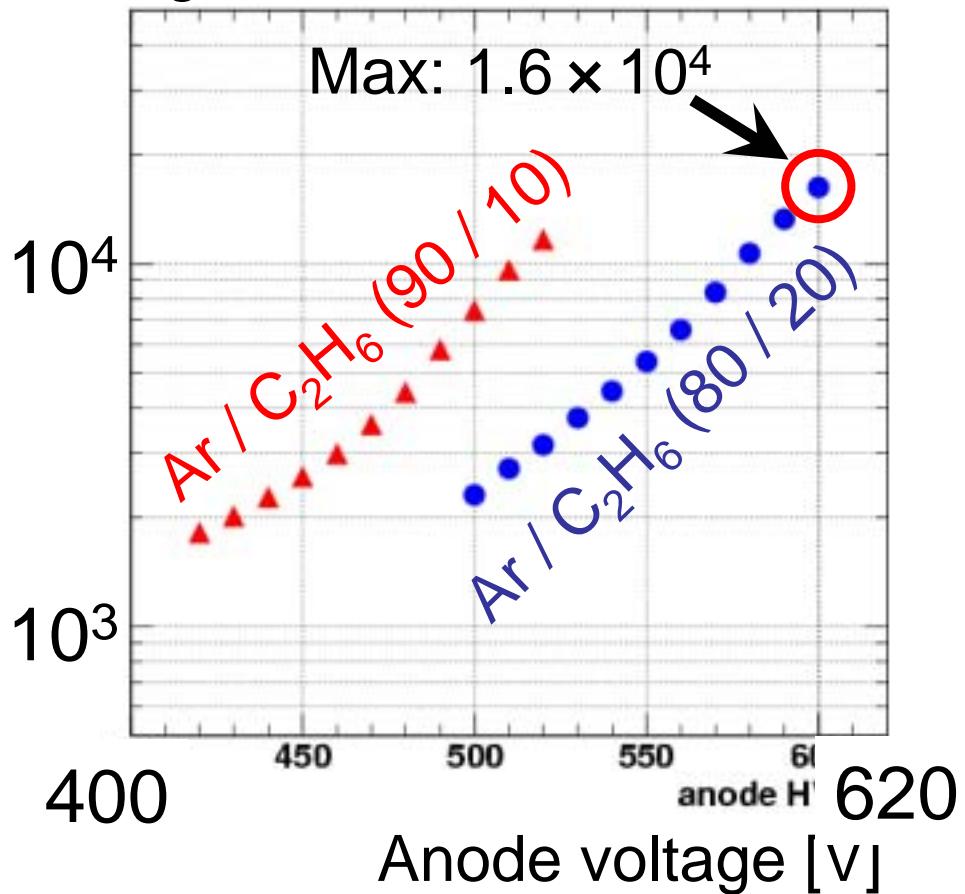


Detection area = 100cm^2

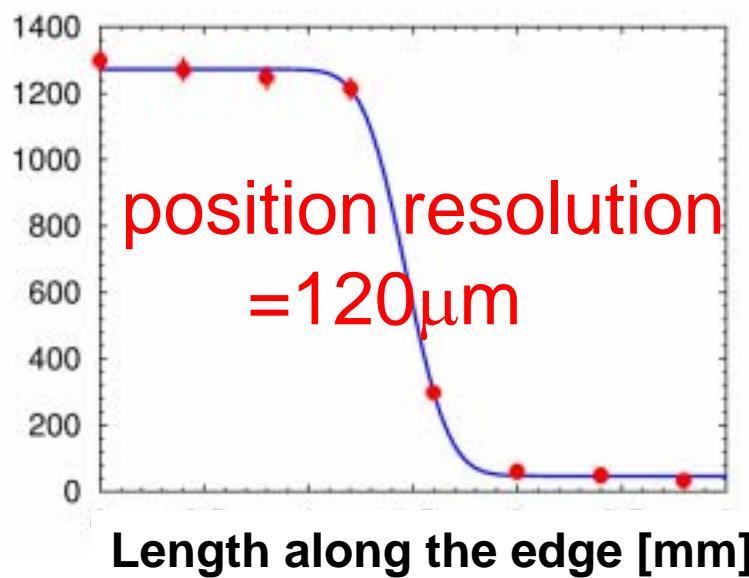
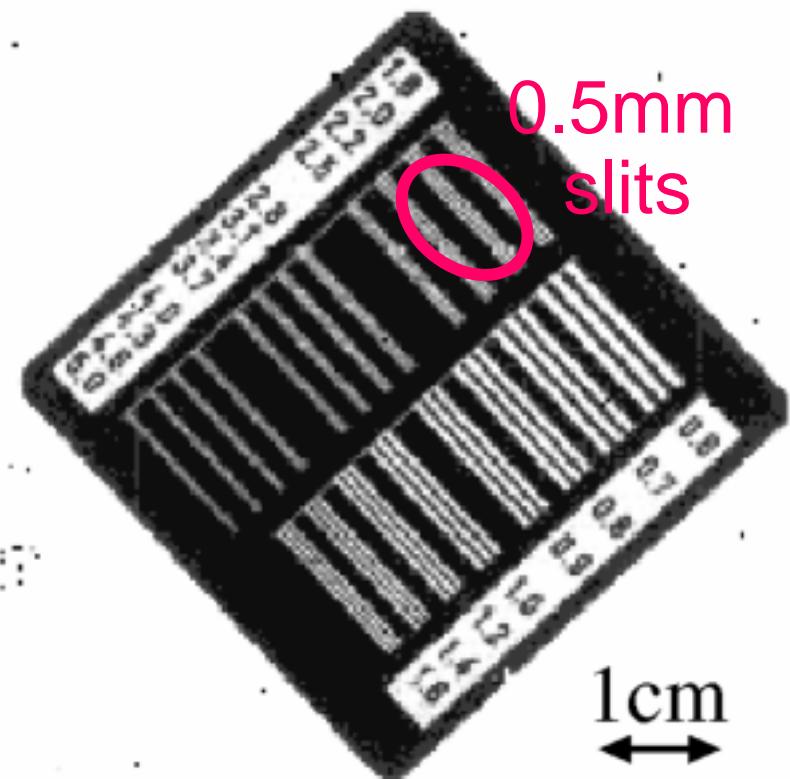
- $400\mu\text{m}$ pitch electrodes
- 256 anodes and
256 cathodes

Performances

Gas gain



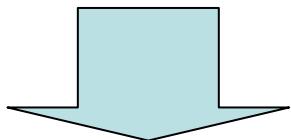
Gas gain { Max: 1.6 × 10⁴
Stable: ~6000



Next development

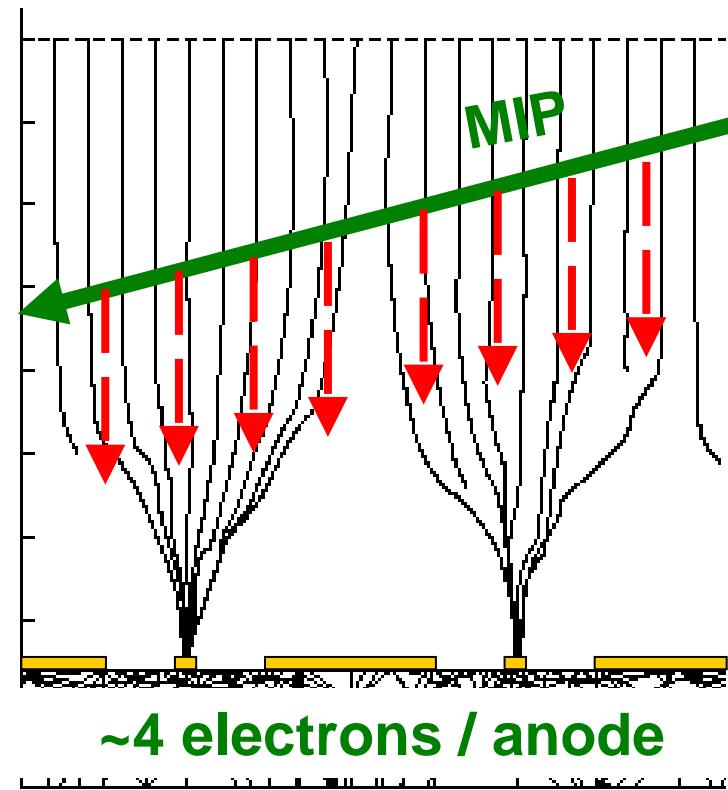
Current status

- Max gas gain $>10^4$
- Stable operation (>1 month)
@ gas gain ~ 6000



Next step

- Stable operation @ gas gain $> 10^4$
- Detection area = $30 \times 30\text{cm}^2$

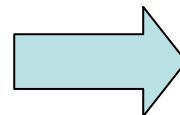


← Tracking of
MIPs

Simulation study for
optimization of the electrode

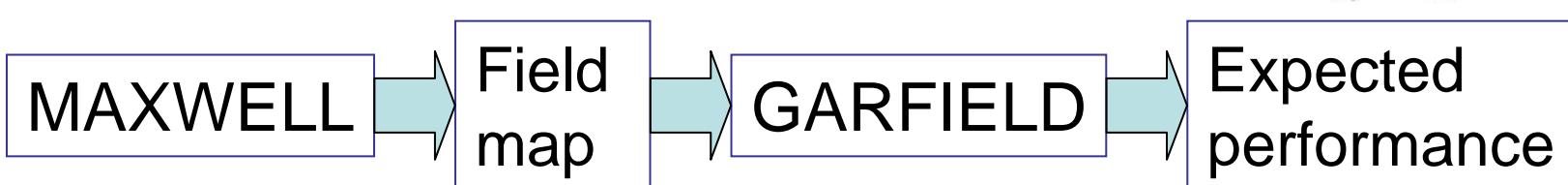
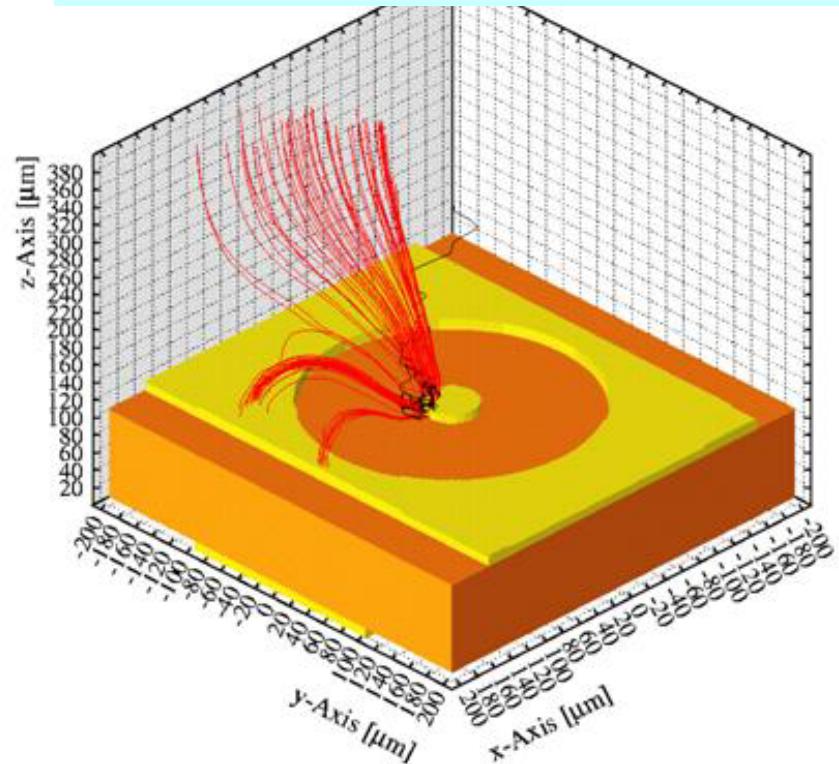
Simulation

μ -PIC ... 3D structure
Dielectrics



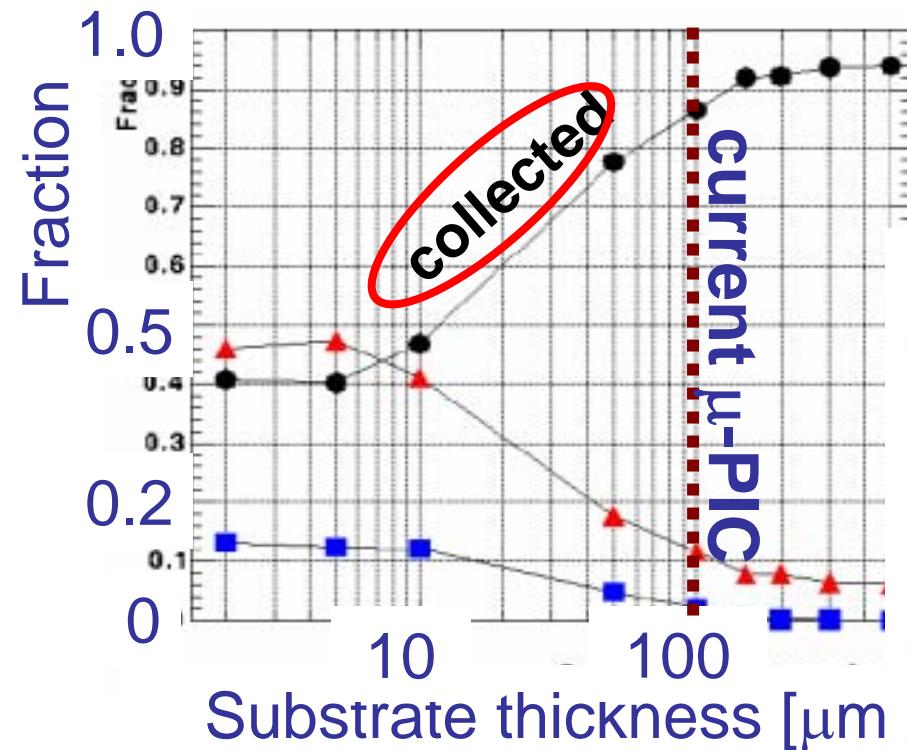
Maxwell & Garfield

- Maxwell
 - 3D structure
 - Finite element method
- Garfield
 - Electron drift
 - Gas multiplication

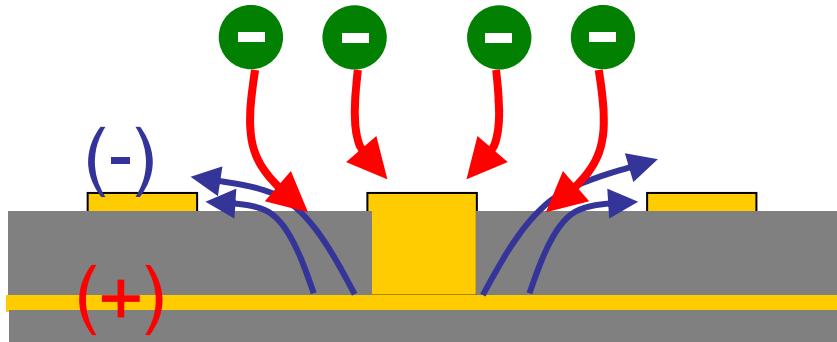
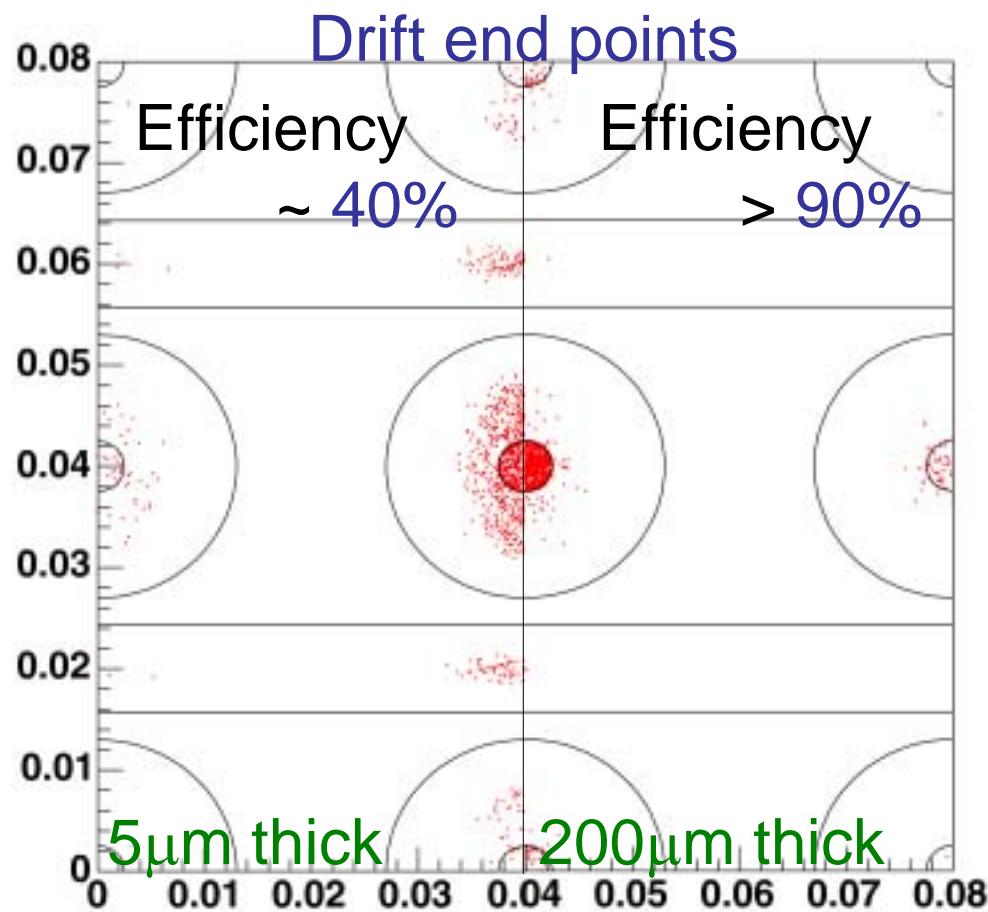


Electron collection

Dependence on substrate thickness

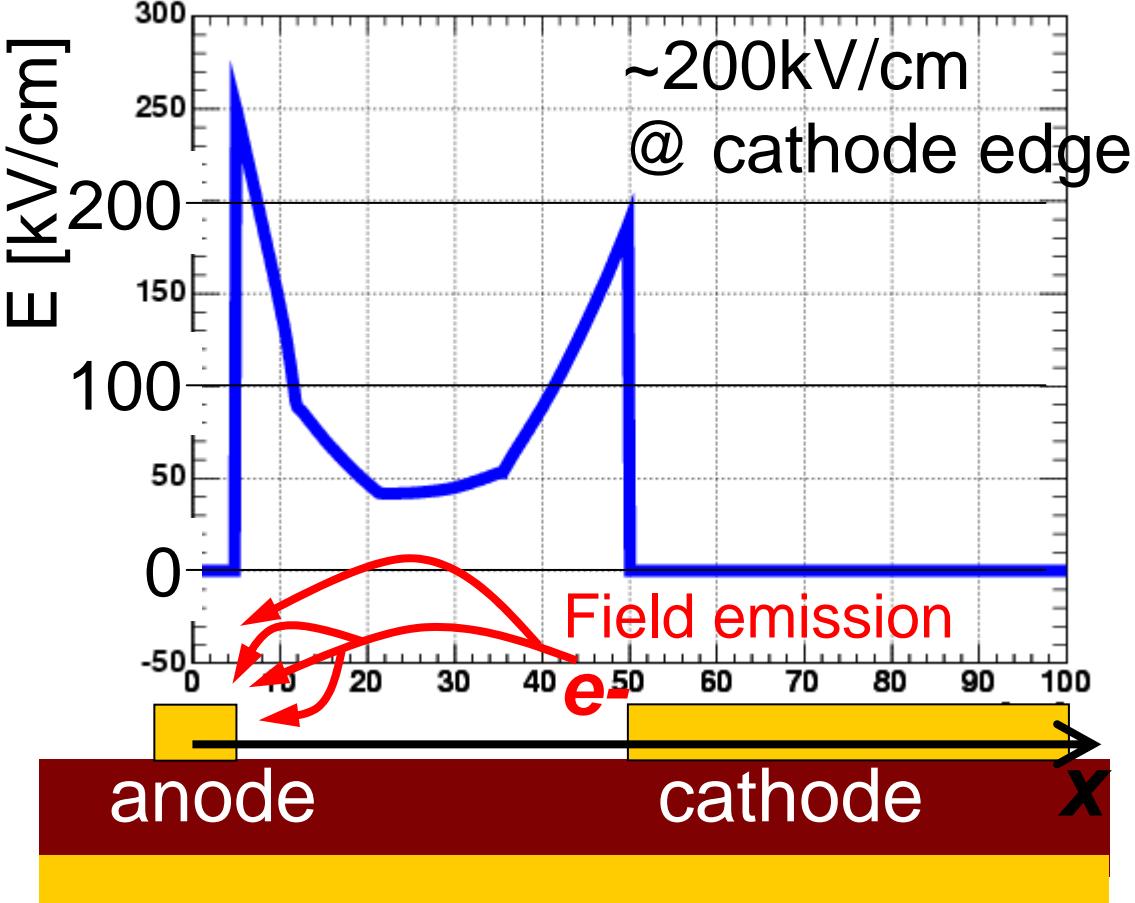


Thin substrate \rightarrow low efficiency
 \rightarrow small signal

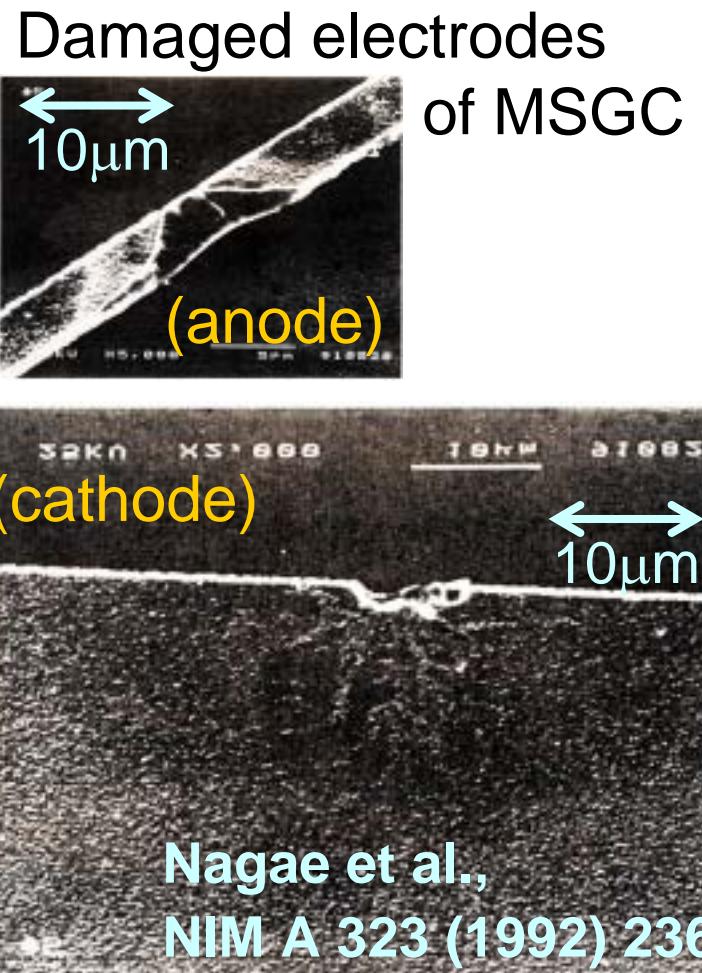


Discharge

~ Limit of MSGC ~



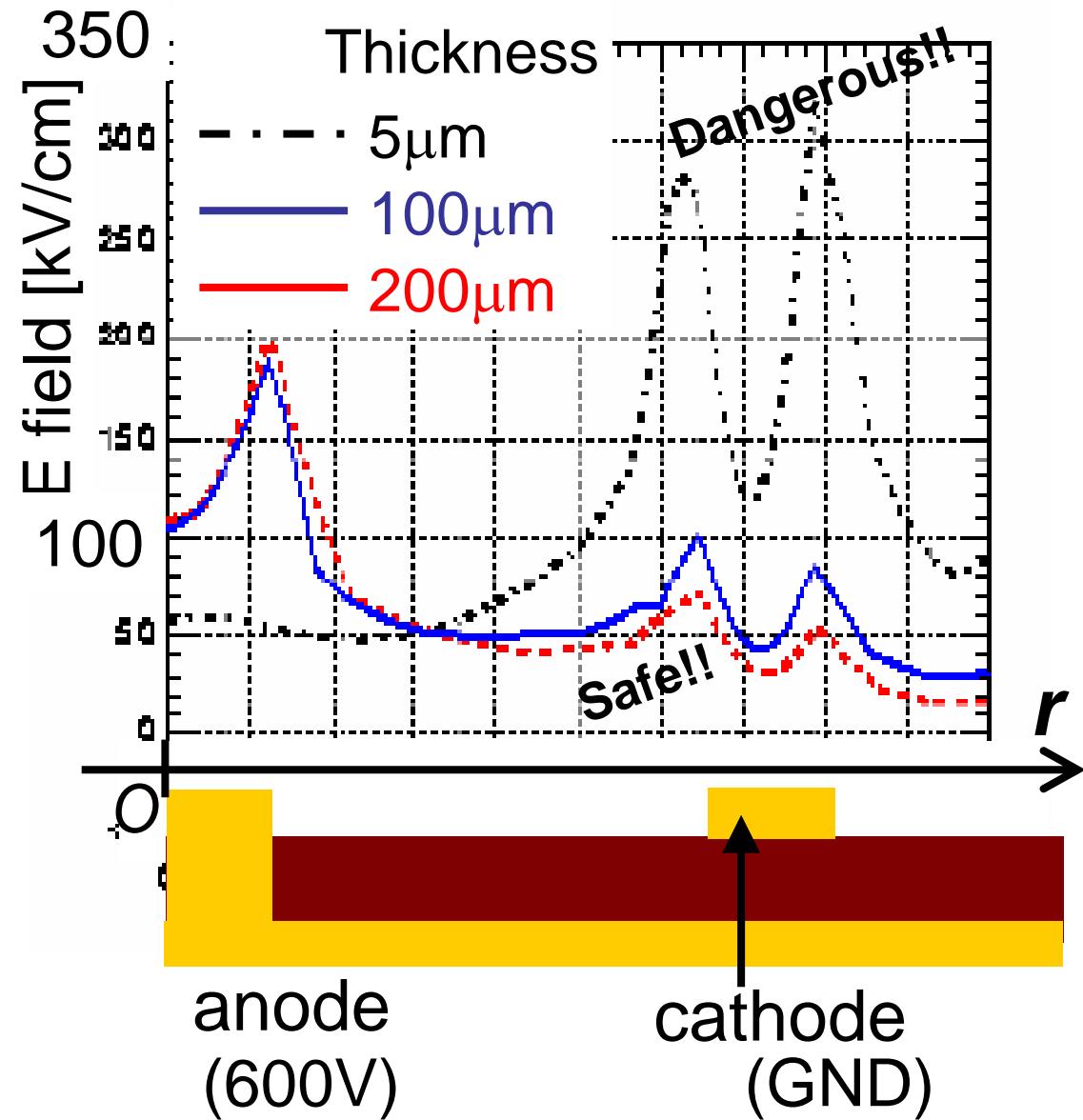
High field \rightarrow field emission
... one of the discharge mechanisms



To avoid discharge:
Low electric field
@ cathode edge

Electric field

Dependence on substrate thickness



Thin substrate ...

- High electric field @ cathode edge

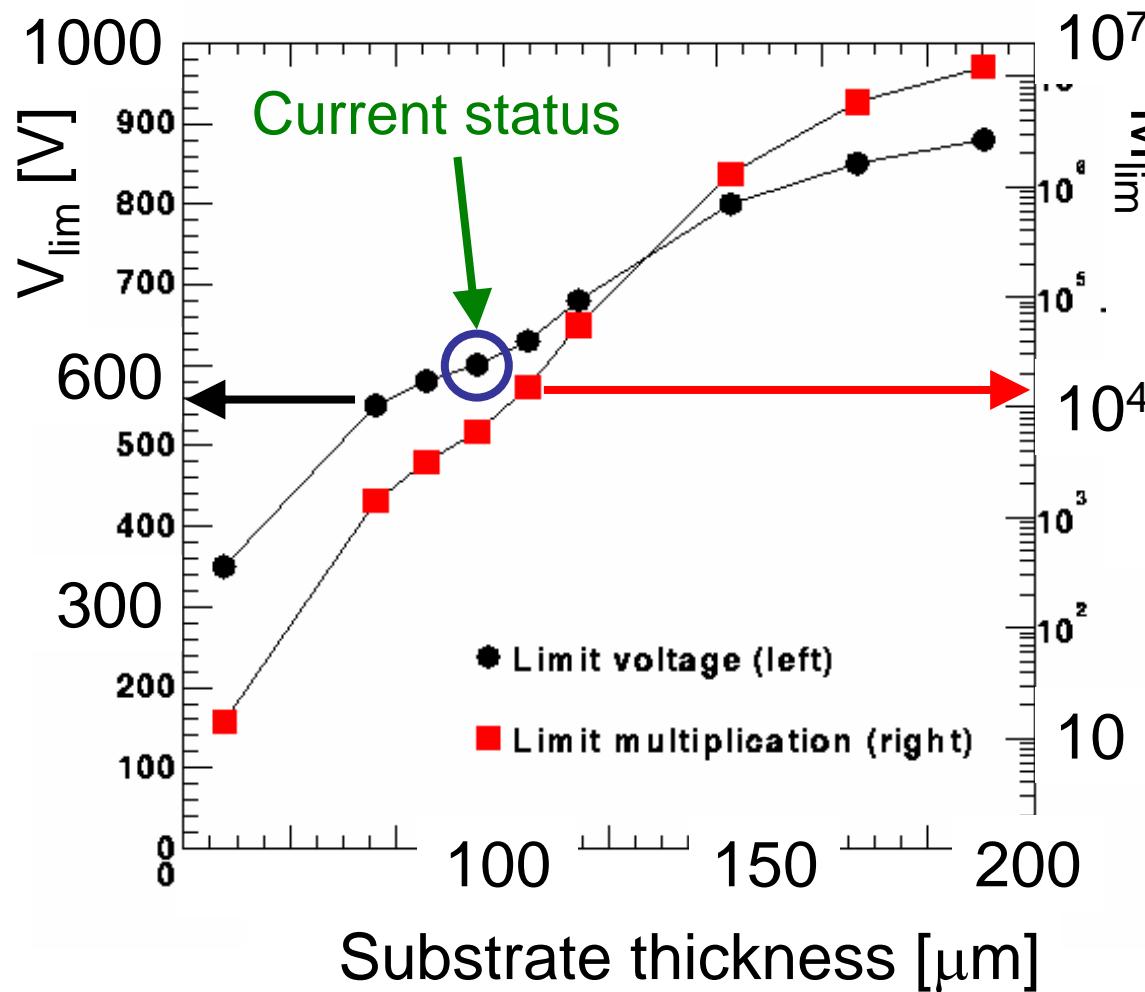
→ Discharge

- Low electric field @ anode top

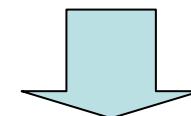
→ Low gas gain

Substrate should be **THICK**.
($> 100\mu\text{m}$)

Maximum gas gain



Experiment
→ $V_{\text{lim}} = 600\text{V}$
(Thickness=100μm)
 $E \sim 200\text{kV/cm}$
@cathode edge



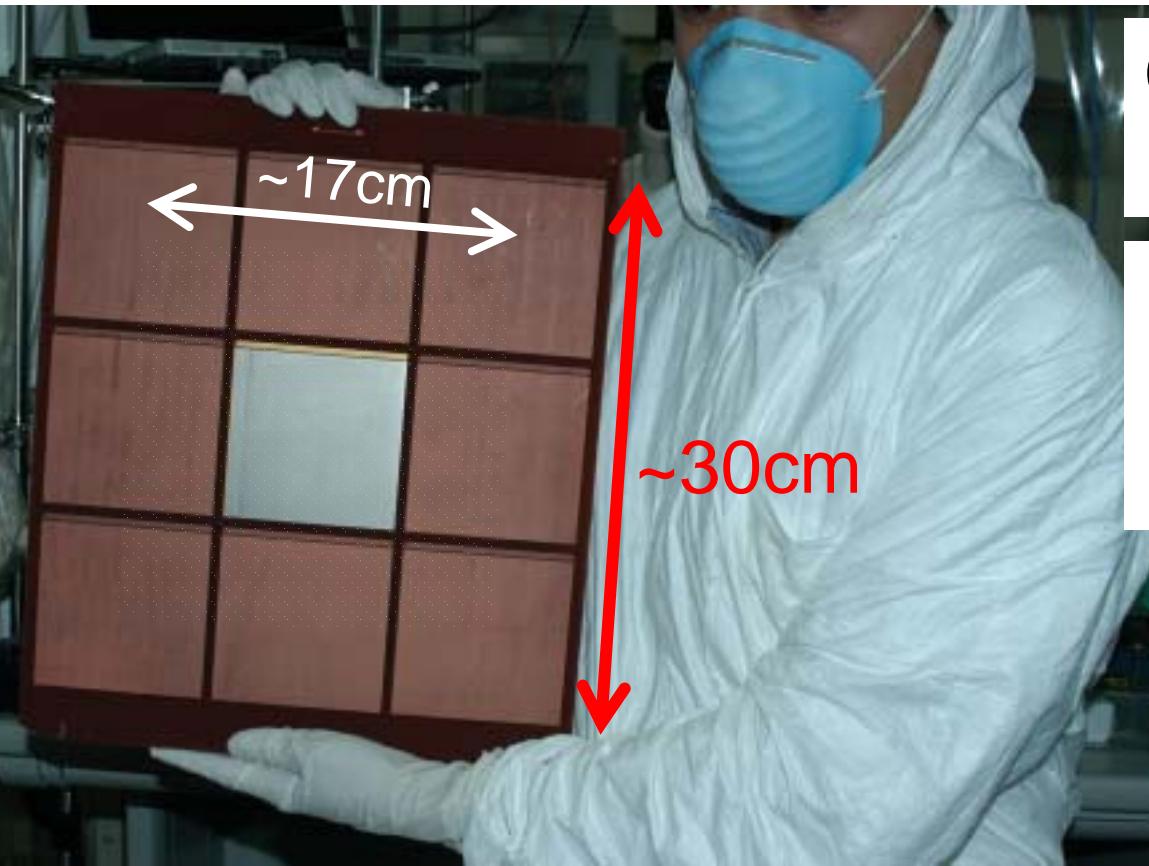
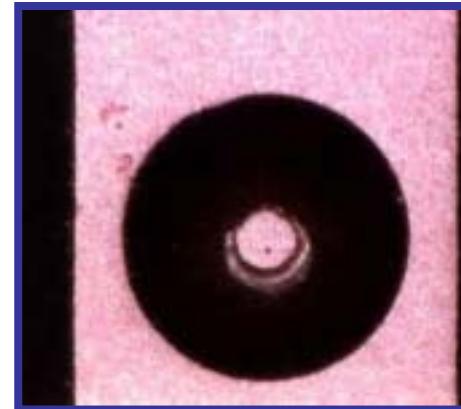
V_{lim} for each thickness
→ M_{lim}

Thickness = 150μm
→ $M_{\text{lim}} > 10^5$

$30 \times 30\text{cm}^2$ μ -PIC

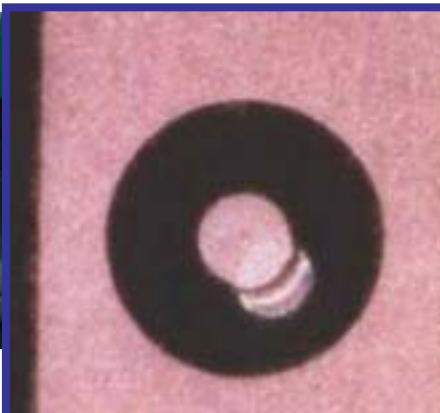
9 μ -PICs on 1 substrate

→ Single $30 \times 30\text{cm}^2$ detector is feasible.



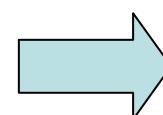
Center $17 \times 17\text{cm}^2$
→ very small offset

Edge region
→ thermal expansion
should be corrected



Summary

- Micro Pixel Chamber (μ -PIC)
 - Gas gain $>10^4$ (max)
 - Position resolution $\sim 120\mu\text{m}$
- Optimization of the electrode structure
 - 3D simulation using Maxwell & Garfield
 - Thicker substrate ($150\mu\text{m}$) \rightarrow gas gain $>10^5$
- Next development
 - $30 \times 30\text{cm}^2$ area detector
 - $150\mu\text{m}$ thick substrate
 - High quality electrode



gas gain $>10^5$
in near future

